L	Hits	Search Text	DB	Time stamp
Number				
3	3830	(219/390 or 219/405 or 219/411 or 392/416 or	USPAT	2004/11/09
		392/418 or 118/724 or 118/725 or 118/50.1 or		14:52
		118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)	1	
4	1095	((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		14:53
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1		
5	66	(((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		14:56
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((elongated or bar) near10 lamp\$1)		
7	6	((((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		14:57
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((elongated or bar or tube) near10 lamp\$1))		
		and (flash near10 lamp\$1)		
6	162	(((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		15:21
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((elongated or bar or tube) near10 lamp\$1)		
8	11	((((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		15:07
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((elongated or bar or tube) near10 lamp\$1))		
		and (((heat\$3 or hot) near8 plate\$1) and		
		preheat\$3)		
9	20	((((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		15:08
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
	•	((elongated or bar or tube) near10 lamp\$1))		
		and (((heat\$3 or hot) near8 (plate\$1 or		
		susceptor\$1 or holder\$1 or support\$1)) and		
		preheat\$3)		

10	9	(((((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		15:08
		or 118/728 or 118/729 or 118/730).ccls. and	ľ	
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((elongated or bar or tube) near10 lamp\$1))		
		and (((heat\$3 or hot) near8 (plate\$1 or		
		susceptor\$1 or holder\$1 or support\$1)) and		
		preheat\$3)) not (((((219/390 or 219/405 or		
		219/411 or 392/416 or 392/418 or 118/724 or		
		118/725 or 118/50.1 or 118/728 or 118/729 or	!	
		118/730).ccls. and (substrate\$1 or wafer\$1))		
		and lamp\$1) and ((elongated or bar or tube)		
		near10 lamp\$1)) and (((heat\$3 or hot) near8		
		plate\$1) and preheat\$3))		
11	748	(((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		15:22
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((heat\$3 or hot) near8 (plate\$1 or		
		susceptor\$1 or holder\$1 or support\$1))		
12	25	((((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		15:24
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((heat\$3 or hot) near8 (plate\$1 or		
		susceptor\$1 or holder\$1 or support\$1))) and		
		(transport\$5 near8 robot\$1)		
13	133	((((219/390 or 219/405 or 219/411 or 392/416	USPAT	2004/11/09
		or 392/418 or 118/724 or 118/725 or 118/50.1		15:26
		or 118/728 or 118/729 or 118/730).ccls. and		
		(substrate\$1 or wafer\$1)) and lamp\$1) and		
		((heat\$3 or hot) near8 (plate\$1 or		
	1	susceptor\$1 or holder\$1 or support\$1))) and		
		((lamp\$1 near8 (above or over or top)) near8		
	I	(substrate\$1 or wafer\$1))	I	